IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant(s)	Alexander et al.)
Serial No:	10/523,164) Examiner:) Robert S Loewe
Confirmation No:	1418)
Filed:	August 29, 2005) Art Unit:) 1796)
For:	FIRE RESISTANT SILICONE POLYMER COMPOSITIONS))

DECLARATION UNDER 37 CFR § 1.132 OF PULAHINGE DON DAYANANDA RODRIGO

Commissioner of Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Dear Sir:

- I, Pulahinge Don Dayananda Rodrigo; hereby declare:
- 1. I am the Pulahinge Don Dayananda Rodrigo, named as an inventor in the application.
- 2. I am qualified as a Materials Scientist having obtained the degree of Doctor of Philosophy (PhD) in Materials Science from the University of Limoges, France, in 1986.
- 3. My work experience includes over 20 years in the materials industry involved in research and development of ceramic materials. Since 2002 I have been employed as a Senior Research Fellow, at Monash University, Clayton, Victoria, Australia, in which capacity I have conducted research in relation to polymeric compositions filled with inorganic materials, which, in a fire, form a ceramic so as

to provide a barrier to the spread of fire and/or preserve communications cables required for evacuation, or fire fighting in the event of a fire.

A copy of my work listing is enclosed as Exhibit 1 hereto.

- 4. As a result of my qualifications and work experience, I have attained a high level of knowledge in relation to the chemical and physical properties of ceramics in general and, in particular, filled polymer compositions which form a ceramic residue in a fire.
- 5. I have read the Examination Report of January 30, 2009, in which the Examiner has rejected the claims.
- 6. The Examiner has referred to a translation of JP55-078073 (Mizutani et al.) which I have read and understood.
- Mizutani refers to an option of adding glass frit. The reader of Mizutani is lead by Mizutani to use an amount of glass frit of 15%. In Example 3 on page 14 of the translation (which contains the only teaching regarding the amount of glass frit), Mizutani directs the reader to use 15% of the silicone base composition of phosphate frit having a softening temperature of 650°C. Mizutani also uses a significant amount of devitrified mica glass. Devitrified mica glass prepared by melting a mixture of oxides and a fluoride as described in page 5 (second paragraph) of the translation of JP55-078073 is a synthetic glass ceramic and contains a significant proportion of glass (20% as given in Example 1).
- 8. It is important to note that the material is prepared as a coating and is therefore diluted with a large volume of solvent. In the examples the composition contains 250 parts 1, 1, 1-trichorethylene as the solvent and 100 parts of other components. In each case, the amount of silicone resin in the coating is 8.6% of the coating composition (30% of composition other than solvent). The phosphate frit is present in an amount of 4.28% of the total coating or 15% of components other than solvent.

- The Mizutani therefore addresses the approach to fire protection used by Landin
 et al. in the sense that it uses a system requiring a very large proportion of
 solvent.
- 10. The Examiner has considered Mizutani et al. with Takahashi et al. US Patent 5061736 which I have read and understood.
- Although the two patents (Takahashi et al. and Mizutani et al.) are from the same field of endeavour in the very general sense that they relate to compositions containing silicone rubber for fire protection, they nonetheless disclose very different approaches to the problem of fire protection. Their approaches are so different that their teachings can not sensibly be considered together. They merely provide alternative approaches to fire protection which might be useful in different end uses.
- 12. As I have discussed above, Mizutani et al. relates to a coating composition containing a large amount (over 70%) of a solvent.
- 13. Takahashi on the other hand, is concerned with forming a foamed silicone rubber body having a cellular structure. The Takahashi composition therefore needs to form a sufficiently viscous material to trap and support a dispersed gas phase. The presence of large amounts of solvent required by Mizutani et al. are incompatible with forming a foamed composition as solvent in such high proportions will not trap or form a dispersed gas phase with a blowing agent.
- 14. Takahashi et al. teach a foamed silicone composition which calls for the presence of (b) silica filler, (c) powder of ferrite, (d) flakes of mica or sericite, fibres of ceramics and glass" (e) platinum compound or metal, (f) curing agent for silicone rubber and (g) blowing agent to produce a cellular structure. Although Takahashi component (d) is a material selected from "flakes of mica or sericite, fibres of ceramics and glass" Takahashi et al do not teach the use of mica in combination with glass. Indeed it is clear from the examples that mica and glass are regarded as alternative choices for component (d). The discussion of component (d) in columns 5 and 6 makes it clear that the amount of the

component to be used is different for each of these options. Takahashi et al. at column 6, lines 36 to 41 states that when component (d) is a glass powder the preferred amount is 20 to 200 parts by weight per 100 parts diorgano polysiloxane. Further ,the base composition demonstrated by Takahashi (see Example 1 at column 10 lines 5 to 19) does not contain either mica or glass or other option for component (d) and in each of the invention composition of Takahashi one only of the options of component (d) is used and not a combination of glass and mica as required in the present application. Accordingly Takahashi et al have not considered the combination of mica and glass let alone the interaction of glass and mica.

- 15. The importance of both mica and glass fibre or frit in the present invention and their interaction is discussed in the specification of the present application such as in paragraphs [0025] and [0039].
- 16. The present application demonstrates in Example 1 that the amount of glass frit and its interaction with mica has a significant effect on the dimensional stability of the silicone compositions in a fire. The following tests were carried out under my supervision in preparation of the present application and in particular Example 1 reported therein:

Specimens of dimensions 38.1 mm x 13.3 mm x 1.7 mm, made from thermally crosslinked (170° C., 30 minutes, 7 MPa) compositions containing the silicone elastomer and peroxide with 20% wt/wt and 30% wt/wt mica and differing levels of a low softening point glass frit, were heated to the temperatures indicated at 10° C. for 30 minutes in air. The percentage changes in volume for the cooled samples are given in Table 1 below. The results show that if the levels of the glass frits are increased to 10%, there is significant shrinkage of the compositions at 1030° C.

TABLE 1

TABLE 1: The effect of mica levels, glass frit levels and firing temperature on percentage volume change.

Silicone/mica/peroxide (78:20:2)	+7	+1
Silicone/mica/glass frit A/peroxide (73:20:5:2)	+7	0
Silicone/mica/glass frit A/peroxide (70.5:20:7.5:2)	-1	-7
Silicone/mica/glass frit A/peroxide (68:20:10:2)	+6	-22
Silicone/mica/glass frit A/peroxide (63:30:5:2)	+7	-1
Silicone/mica/glass frit A/peroxide (58:30:10:2)	+2	-45

17. The tests demonstrate that 10% glass frit in the silicone and mica composition produces a significant shrinkage of the material in a fire. The finding of improved dimensional stability for the composition with 0.3 to 8% w/w glass frit or fibre is important finding because dimensional stability is critical for many articles, such as cable, to maintaining effective insulation during a fire. Severe shrinkage, such as 22% or 45% shrinkage in volume exhibited by compositions containing 10% glass frit at 1030°C produces strain in cable insulation layer and other fire barrier articles increasing the incidence of cracking and severely compromising insulation of important communications, power and barrier structures against the fire. In fire situations the effective insulation of communication and power systems against extreme heat and electrical short circuiting is critical to enabling the safe evacuation of people present at the time of the fire and to maintaining the essential systems for fire fighting. The relative dimensional stability of compositions of the invention when compared with corresponding compositions containing more than 8% glass frit or fibre demonstrates a significant improvement in fire protection.

I further declare that all statements made in this declaration of my own knowledge are true and that all statements made on information and belief are believed to be true; and further, that these statements were made with the knowledge that wilful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that wilful false statements may jeopardize the validity of the application or any patent issuing therein.

Date: 20.04.2009

Pulahinge Don Dayananda Rodrigo

(19) 日本国特許庁 (JP)

⑩特許出願公開

⑩ 公開特許公報 (A)

昭55-78073

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(全 5 頁)

9耐熱塗料

②特

願 昭53—152871

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明 細 書

1, 発明の名称 耐熱強料

2. 特許請求の範囲

1 少くとも、シリコーン樹脂とデビトロ化した マイカガラスとを配合して成る耐熱塗料。

2 耐熱衛料はフッ素金雲母を含有して成る特許 請求範囲第1項記載の耐勢衛料。

3 耐熱強料は天然層状構造鉱物を含有して成る 特許構求の範囲第1項又は、第2項記載の耐熱 冷點。

4 耐熱 徴料 は ガラスフリットを含有して 成る 特 杵請 京範 開 第 1 項 、 第 2 項又 は 第 3 項 記 戦の 耐 勢 牽料 。

3. 発明の詳細な説明

本発明は、高温暖域でデビトロ状セラミック 質皮膜を形成することのできる耐熱微料に関す るものである。

従来、300 で以上の高温度において使用ができる耐熱機料として、ピヒクルにシリコーン系樹脂を用い、これに執的特性改善のための各種の

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無機質粉末を添加した組成物が知られている。無機質粉末の種類としてはアルミニウム、亜鉛のような金属粉末、天然貫母、タルク、モンモリロナイトのような天然維浄な物、その他災寒、炭化物、硫化物、硝化物、けい化物、金属酸化物、ガラス質物のようなセラミック質物がある。

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化現象があらわれ、耐熱強緩の性能を失うよう になる。

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こりした劣化現象の改善法として低酸点から 馬触点にいたるガラスフリットを添加し、シリコーン樹脂のシロキサン化する温度領域(300°C ~ 500°C)でガフスフリットの軟化敵増により 増輝の劣化を防ぐ方法が採られている。しかし との方法による結合の母能はガラス質マトリッ クスによるものであるので、無受物粉末とのぬ れ性、被繁美体との影暖係数差、冷熱の繰減し によるクリーブ等が原因となり、ストレスる。 生して捨膜は経時的に劣化するよりになる。

本稿明は上記した従来の対熱を料の欠点を改善したもので、少くとも、シリコーン制脂とデビトロ化したマイカガラス(以下とれをマイカガラスと略称する)とを配合して成る耐熱強料を特徴とするものである。

本発明はシリコーン
関脂とそれが分解する高温度におけるデビトロ化したマイカガラスとのセラミック化反応により、デビトロセラミック質皮膚

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を形成し、長期間にわたる高額底域で冷・熱を繰返しても損傷を起こすことがない耐熱強料を提供しようとするもので、この場合セラミック反応はシロキサンとマイカガラスとの固相体反応であり、従来の天然震母とシロキサンとガラスフリットとによって形成される単なるガラス触着被吸とは本質的に異るものである。

デビトロ化したマイカガラスは、K2O-MgO-MgF2 --SiO2 組成による物質で、たとえば 0.5K2O・1.5MgO・MgF2・4SiO2 のモル比で配合したバッチを少くとも 1,300 ℃ 以上で溶験し、その溶験体を急冷することによって海られる。たとえば 1,400 ℃ の再験体を 10 ~ 20 分で 1,000 ℃ まで冷却すると、その職境の量によっても異るが、ガラス中に 70 ~ 80%のカリ四ケイ素雲母 (KMg2s (Si 4O10)F2)を折出したデビトロセラミックスが得られる。そしてこのデビトロセラミックスは冷却速度が早い程ガラス成分比は多くなる。

マイカガラスはカリ四ケイ深須母結晶を折出し たセラミックスであるので、容融体は粘度が大き

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く、との組成以外のファ素雲母の成分の格骸体に 比べてマイカ結晶の生成がしにくく、過冷却によ り容易に 100 %から 5 %付近までのガラスとなる という特徴をもっている。

本発明において、半触状で強アルカリ性であるマイカガラスは、シロキサンのような非晶質のSiO2 分を存解してガラス化する作用と、600 ℃付近より環放する少量のファ化物、KF, SiF4 等のガスが SiO2 の啓離点を低下させる作用とが協同して、900 ℃付近よりマイカガラスとシロキサンとの境話が始まる。またマイカガラスは、多くのファ素提母や天然異母等の膨脹係数が 10 × 10⁻⁶ で「以上であるのに較べて 4~5 × 10⁻⁶ で「であるから、マイカガラスの配合された強減では無急冷に対してストレスが少く損傷を起さない。

本発明においてはシロキサンとマイカガラスとのセラミック化反応を安定に行なわせるとともに, 低温度域での破膜の可撓性や高温度域での熱的特性を向上させるため、シリコーン樹脂とマイカガラスとの配合物に、マッ素金盛母又は金雲母、白

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選母、パーミャュライトのよりな天然の解状構造 敷物を添加するのが好ましい。

即ち、上記したシロキサンとの焼結を 600 ℃位から行なわせることができるマイカガラスは、 筅 結性にすぐれてはいるが、 比較的劈開性が小さい、 そとでアスペクト比の大きいフレークが強膜内で 被 衛装物表面と平行に且つ 質なり合って 連続する 組織を形成するようにする、

ファ東金賀母はファ東雲母の代表的な品種であり、特晶性が高く、野朝性が発達しており、物砕によりアスペクト比 50~ 100 程度の良好なものが容易に得られる。そしてマイカガラスとは 1,100 で付近より 間体間反応で固務体を形成しセラミックス化する。これはマイカガラスの半機状で起きるセラミック化であるので、破膜は流動せず安定している。また天然雲母等も良好なアスペクト比のフレークが容易に入手でき、速度に可挽性を付与するとともに、高温度においてマイカガラスとりは組織内で他の成分と減難する。そしてへき開が

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良好に行われる天然層状構造鉱物なら、金雲母、白雲母、パーミキュライトをはじめ他の品種のものも使用でき、これらは単味でもフッ素金雲母と、の併用でも効果上変るところはない。

さられ、本条明においてはシリコーン樹脂とマイカガラスとの配合物にガラスフリットを添加することが、好ましい。 申ちガラスフリットの希加はセラミック化の過程において、シリコーン樹脂のシロキサン化が始まる 350 でより、マイカガラスとシロキサンの関群が始まる 900 で付近までの教練のクラックの発生や制能を防ぐとともに、 年知 900 で以上ではフッ素 雲 ジャーキサン系のセラミックス化反応に参加し、デビトロ形式のセラミック皮峻を形成するととである。

ガラスフリットの模類としては側腰塩、側けい ははは、破けい機道等が使われる。これらのガラス フリットには軟化点が350℃から900℃位のもの があり、破膜の使用温度領域や被乗表物の材質等 により減宜機択する。

マイカガラスは半般状態よりほう酸塩、りん液

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塩とは相互に融合して界面に新しいガラスを形成なする。そしてこの融合ガラスと同様のものである。これはいのものの形成と同様等する。といるというである。などのであると、そのでは、大きい、アスペクトとの良好なフレークを強くとうに、アスペクトといると、が変なかと、対しているので、があるのでもる。

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時は可機性を保持し、幅端な温度変化たとえば火火、病機会調系沫やアークが微れるような無機機構を充め、変換にはシリコーンゴム系のものが、また無硬化処理のできない大きな被漁装物たとえば、船舶、内機機関、留炉港将将の不燃化漁科には常な性の他の関係とのコールドプレンド側のも本発明の大沙川県底が500℃以上あって始めから本発明のセラミック化反応が行なわれたものを使うような用海ではシロキサン成分の多いシリコーン関係を使用する。

本発明の配合組成は、シリコーン樹脂(周型分 陳等)5~90%、マイカガラス95~10% の組合 せを基本とし、これにファ 表金雲母、天然層状構 着鉱物、ガラスフリット部を適宜選択して添加す るものである。そしてこの研究のほかに、精色類 科、体質域料、金銭粉末を加充しとは余額物性 を摂わない範囲で適宜加えられる。

以上说明したよりに本発明による射熱強料は、 常媼より少りコーン樹脂の分解する温度までの用 余にとどまらず、さらに将 1,000 ℃ までの鳥鶥度 領域でも使用できる。この場合組成分のシロキサンとマイカガラスとの固溶体形成を基本反応とし、これにファ素金質母や天然解状構造鉱物。さらにはガラスフリットの加ったデビトロ質ガラスを結合マトリックスとしたセラミック皮膚が被塗装体に形成されるもので、その皮質は弾性フレークの乗り合った組織であり、可続性、射熱衝撃性および長期にわたる冷熱サイクルにすぐれた対人力をそかえている、

つぎに本端明の軒熱強料の製造例を示す。 例 1

マイカガラス: 0.5K2O・1.5MgO・1.1MgF2・4SiO2の配合を1.45mC~1.50mCで溶敝し、客動体を空気中で1.00mCまでを20分で含却し、Kyg2・5(Si4O10)F2の結晶約80%とガラス質20%の合成塊を得,とれを粉砕して原料に供した。

重量比で、シリコーン樹脂(信徳化学製 KR275)を固型分換算で 30 %、マイカガラス(325 メッシュバス)58 %、酸化亜鉛 6 %、 磁料セラミックブラック 4 %、ノニオン系分散剤 1.5 % 及び オク

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この余料を 100 mx × 100 mx × 1.5 mx の鉄板の片面に強接し、約 60 分間風乾し、ついて温度 180 ℃で 30 分間加熱して硬化させ、 0.15 mx 準の強度を得た、これを 200 ℃から 500 ℃まで 60 分、500 ℃から 900 ℃まで 30 分の温度条件で加熱した。 得られた途短は灰無色の平滑面を持ったセラミック複皮膜であった。これを常候から 400 ℃の電気炉中に入れて 10 分保持した後、空気中に没り出し、10 分間放冷して 1 サイクルとする冷熱炭験を 20 回繰り返したが微調には損傷はたかった。

例 2

マイカガラス:例1と同じものを使用する。 フッ表を選母:フッ素を選母をボールミルで 48 時間選式粉砕し 水暖をした暖 200 メッシュバス のものを採取した。このものは平均粒径 58 × で あり、潤子順勾鏡写真による複繋によればアスペ クト比が 50 ~ 100 の範囲であった。

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(フロゴバイト系) 200 メッシュバス, 平均粒(類) 147 A であり、電子頻 微鏡 写真の 戦祭によれば アスペクト比は 60~ 120 の範囲であった。
(A) 重量比で、シリコーン 樹脂 (首級化学型 Kib-2038) 固型分換算で 30 %、マイカガラス 325 メッ

天然貫母はガナダ、ケベック州産スズオライト

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度に折り曲げても折目はつかなかった。とのテープで耐火電線(架礁ボリエチレン電線 22ml)10本をまとめてテープで3 電券をに採束して、プンゼンパーナーでテープ雨が900~1,000 ℃ 位の温度にたるように加快したが、A、Bいづれの環境も不燃性で加勢能はセラミックス状の吸皮が形成されていた。

柳 3

マイカガラス及びフッ共会 賞母は例2と同一のもでのを使用した。

との考料を 100 mm× 100 mm× 1.5 mmの鉄板の片 面に急収し、 30 分間風乾した後、 180 Cで 30 分

間加熱し硬化させて 0.15 軸の密膜を得た。この鉄 板を電気炉中で 200 ℃から 500 ℃まで 60 分, 500 ℃から 900 ℃まで 30 分、 900 ℃で 30 分の温度条 件で加熱した。鉄板上の金融は乳白色の琺瑯状の セラミック皮膜であった。とれを 500 ℃に保持し た耐気炉中に入れ、 10 分間加熱した後、 空気中 **に取り出し10 分間放冷して1 サイクルとする冷** 単試験を20回機返したが透膜に損傷はなかった。 (R) 重量比でエポキシ変性シリコーン樹脂(信性 化学製 81001) を問型分換算で 40 %, マイカガ ラス 325 メッシュパス 20 %, 天然 製母 325 メッ シュパス 15 %, 硼けい 独質 (無鉛) フリット (軟化福度 550 ℃) 15 %。 セラミックプラック 325 メッシュパス 8 %。 分散制 1 % 及び宏装改良 剤1%の組成物を 100 部とし、これにキシレンと MIBK: の混合密媒 (7:3) 250 部が配合された 後料を調製した。との後料を 200 mm× 200 mm× 2 maの判板の片面に微装し、 2 時間風乾した後、温 度 150 ℃で 30 分間加無して硬化させた。この吹 膜顔を 550 ~ 600 でになるようにガスパーナーで

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30 分間加熱して黒色のセラミックス皮膜を形成させた。とれをセラミック皮質面が常時 300 ~350 ℃になるようにガス格で加熱し、それを 300 時間 蝶袴したが皮膜にはクラック。 剣雕等の損傷は起きなかった。

代理人 鳥 居 静 珠层部

DERWENT-ACC-NO: 1980-52610C

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TITLE: Heat-resistant coating compsn.

contg. silicone resin and

dehydrated mica glass

INVENTOR: ITO K; IZAWA T ; KATASAKA M ; MIZUTANI

Т

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BASIC-ABSTRACT:

Paint compsn. contains (a) silicone resin, and (b) dehydrated mica glass. Paint can be used at high temp. ?1000 degrees C, and dehydroceramic film is formed by ceramic forming reaction of silicone resin with dehydrated mica glass at a high temp., at which silicone resin is decomposed. Ceramic film formed on a body to be coated has a texture in which elastic flakes stack and has excellent flexibility, thermal impact resistance and durability against cooling-heating cycle.

Specifically dehydrated mica glass has compsn. of K2O-MgO-MgF2-SiO2 and is obtd. by melting a batch with molar compsn. of 0.5 K2 0.1 MgO.MgF2.4SiO2 at 1300 degrees C and quenching the melt. When the melt at 1400 degrees C is cooled to 1000 degrees C in 10-20 min., dehydroceramic in which 70-80% of potash tetra silicon mica, KMg2.5 (Si4O10)F2 is deposited in glass can be obtd.

TITLE-TERMS: HEAT RESISTANCE COATING COMPOSITION
CONTAIN SILICONE RESIN DEHYDRATE
MICA GLASS

DERWENT-CLASS: A26 A82 G02 L02

CPI-CODES: A06-A00E1; A08-R06; A12-B01C; G02-

A01A; L02-G06;

POLYMER-MULTIPUNCH-CODES-AND-KEY-SERIALS:

Key Serials: 0045 0057 0205 0211 0228 0231

1306 2199 2207 2218 2600 2617

2628 2669 2718 2792

Multipunch Codes: 03& 04- 05- 06- 10& 15- 18& 229

250 308 310 331 360 38- 42- 477

504 541 551 556 560 566 656 721 724 03& 04- 05- 06- 10& 15- 18&

229 250 308 310 331 360 38- 42-

477 504 541 551 556 560 566 656

721 724

PTO 09-0355

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HEAT-RESISTANT COATING [TAINETSU TORYOU]

TOYONOBU MIZUTANI et al.

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DESIGNATED CONTRACTING STATES	(81):	
TITLE	(54):	Heat-Resistant Coating
FOREIGN TITLE	[54A]:	Tainetsu Toryou

Specification

- Title of Invention
 Heat-Resistant Coating
- 2. Scope of Claims
- A heat-resistant coating comprised of at least a silicone resin and devitrified mica glass.
- 2. A heat-resistant coating according to Claim 1, which coating contains fluorine gold mica.
- 3. A heat-resistant coating according to Claim 1 or 2, which coating contains a mineral with a naturally layered structure.
- A heat-resistant coating according to Claim 1, 2 or
 which coating contains glass frits.
- 3. Detailed Description of the Invention

The present invention pertains to heat-resistant coating capable of forming devitrified ceramic film in a high temperature range.

Compositions employing a silicone resin as a vehicle and various inorganic powders added thereto to improve thermal characteristics have heretofore been known as heat-resistance coatings at higher temperatures of no less than 300°C. The types of inorganic powders used include powders of such metals as aluminum and zinc; such naturally

illegible minerals as natural mica, talc, and montmorillonite; and such other ceramic substances as carbon, carbides, nitrides, borides, silicates, metal oxides, and hyaline substances.

While such heretofore used combinations of silicone resins and inorganic powders are somewhat effective in increasing heat resistance, inorganic powder content of 30% or more causes a decline in the faculty of the coating film formed on the object to be coated. In particular, heating the coating to a temperature of 400°C or higher for application reasons results in the sublimation of the organic components of the silicone resin serving as the vehicle evaporate, and while said components transition into an inorganic substance with a siloxane structure (Si-O-Si-O), the siloxane bonds are weak during this period and no bonding whatsoever occurs with the aforementioned inorganic powders; hence, the coating film strength declines, resulting in the formation of minute cracks. Further, such degradation as chalking and peeling occur at temperatures of 500°C and

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higher, resulting in the loss of performance as a heatresistant coating film.

A known method for improving on the degradation

phenomenon involves adding glass frits, having melting points ranging from low to high, and preventing the degradation of coating films through the softening and fusing of glass frits in the temperature range wherein silicone resins transition into siloxanes (300°C ~ 500°C). However, because the bonding illegible according to this method is dependent on hyaline matrix, such factors as the wettability with inorganic powders, difference in expansion coefficient with the object to be coated, and creeping due to repeated cooling and healing cause stress, resulting in the degradation of the coating film over time.

The present invention improves on the aforementioned problems presented by conventional heat-resistant coating and is characterized by comprising at least a silicone resin and devitrified mica class (hereinafter abbreviated as "mica glass").

The present invention seeks to form a devitrified ceramic coating film by ceramifying a silicone resin with devitrified mica class at a high temperature at which the resin decomposes, thereby providing a heat-resistant coating that is not damaged by repeated heating and cooling over extended period in the *illegible* range, and, the ceramification reaction in this case being a solid phase reaction between siloxane and mica glass, said coating film

is basically different in nature from the simple conventional glass fusion coating film formed from natural mica, siloxane, and glass frits.

Devitrified mica glass is a substance with the composition $K_2O-MgO-MgF_2-SiO_2$ that is obtained by melting a batch with a molar ratio of 0.5 $K_2O:1.5$ MgO:MgF2:4 SiO2 at a temperature of 1300°C or higher. For example, when a 1400°C melt is cooled to 1000°C in 10 ~ 20 minutes, 70 ~ 80% of devitrified ceramic comprising precipitated potassium tetra silicon mica $[KMg_{2.5}(Si_4)10]F_2]$ can be obtained in the glass, though the amount varies depending on the size of the illegible cluster. The ratio of said vitrified ceramic to the class components increases as the cooling rate increases.

Since mica glass is a ceramic formed by the precipitation of potassium tetra silicon mica crystals, the melt thereof is characterized by the fact it is less inclined to generate mica crystals compared to melts comprising fluorine mica of other compositions, and that over-cooling easily results in the formation of 100% to about 5% glass.

In the present invention, the sintering of mica glass and siloxane is caused to start at about 900°C the joint action of the half melted and strongly alkaline mica to

melt and vitrify non-crystalline SiO_2 and of the small amount of gas comprising such substances as evaporated fluorides, KF, and SiF_4 , to lower the melting point of SiO_2 . Further, because the expansion coefficient of mica glass is $4 \sim 5 \times 10^{-6} \, ^{\circ}\text{C}^{-1}$ as opposed to the $10 \times 10^{-6} \, ^{\circ}\text{C}^{-1}$ or higher of numerous other fluorine, natural and other types of mica, coating films containing mica glass are not stressed much by rapid heating and cooling and, therefore, are not damaged.

In the present invention, it is desirable to add a fluorine gold mica or gold mica, white mica, or such naturally layered minerals as vermiculite to the formulation comprising silicone resin and mica glass in order to stably conduct the ceramification reaction of siloxane and mica glass and to improve the flexibility of the coating film in the low temperature range as well as the thermal characteristics thereof in the high temperature range.

This is to say that the aforementioned mica glass, which can be sintered with siloxane from about 600°C, has relatively little cleavability although it excels in sinterability. Hence, the coating film is formed so that the structure thereof is such that the flakes with larger aspect ratios are overlap with each other and are parallel

with the surface of the object to be coated.

Fluorine gold mica being a typical fluorine mica that has high crystallinity and high cleavability, those of a satisfactory aspect ratio of about 50 ~ 100 are easily obtainable by pulverization. Through a solid reaction, mica glass begins to form a solid solution and ceramifies from about 1100°C. Since this ceramification takes place when the mica glass is in a half-melted state, the coating film does not flow and is stable. Flakes with satisfactory aspect ratios are also easily obtainable from natural and other mica, and they impart flexibility to the coating film as well as illegible with the other components within the coating film composition due to the glass illegible solution produced between mica glass and siloxane at high temperatures. Any naturally layered mineral that can be

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cleaved satisfactorily may be used, examples of which include gold mica, white mica, vermiculite and other types of minerals, and the effect thereof does not change regardless of whether they are used alone or in combination with fluorine fold mica.

In the present invention, it is desirable to add glass frits to the composition comprising silicon and mica glass. This is to say that the addition of glass frits prevents

the peeling of and the occurrence of cracks in the coating film at temperatures from 350°C, when the silicone resin begins to form siloxane, to about 900°C, when siloxane begins to turn into a solid solution, as well as take part in the ceramification reaction of the fluorine mica and the siloxane series at a temperatures of 900°C and higher, thereby forming a devitrified ceramic coating film.

Examples of the types of glass frits used include borates, borosilicates, illegible, and sulfosilicates. The softening points of these glass frits range from 350°C to about 900°C and may be selected as necessary, depending on such factors as the temperature range at which the coating film is to be used and the material comprising the object to be coated. Mica glass mutually fuses with borates and phosphates from when it is in a half-melted state. It is from this fused glass that potassium tetra silicon precipitates out during cooling. This is similar to the formation process of the so-called devitrified. Of course, the newly formed fused glass fusion bonds closely also with fluorine gold, natural, and other mica. Because a ceramic coating film thus formed has a composition wherein the homogeneous overlap of flakes with high flexibility and satisfactory aspect ratios are closely and strongly bonded with the object to be coated with the devitrified glass

serving as the bonding matrix, it is heat resistant and has excellent heat-cool cycle endurance.

As regards the type of silicone resin used in the present invention, any of straight silicon, modified silicon, and cold blended types may be used. However, the content of the siloxane that ultimately participates in the ceramification reaction is desirably no less than 1/20 of inorganic substances other than the resin, and other illegible are selected depending on the conditions of use for the coating. This is to say that silicon rubbers are used for application on inorganic illegible cloth that maintains flexibility at ambient temperatures and is exposed to extreme temperature changes (e.g., coming into contact with sparks of fire, droplets of molten metal, and arc), cold blends with other illegible resins are used in fireproofing coating for large objects that cannot be subjected to thermal curing treatment (e.g. ships, internal combustion illegible, and illegible), and silicone resins with a high siloxane content are used in such applications where the use temperature is 500°C or higher and those that have undergone the ceramification reaction according to the present invention are used from the beginning.

The formulation composition of the present invention is based on combinations of $5 \sim 90\%$ silicon resin (solid base)

and 95 ~ 10% mica glass, to which fluorine gold mica, naturally layered minerals, glass frits, and other substances are added. Color pigments, extender pigments, and metal powders may be added to the composition as needed to the extent they do not undermine the coating film characteristics.

As explained above, the heat resistant coating according to the present invention is not limited to use in temperatures ranging from ambient temperatures to temperatures at which silicone resins decompose, it can also be used in high temperature ranges of up to about 1000°C. In this case, the basic reaction involves the formation of a solid solution of siloxane and mica glass comprising the composition; a ceramic coating film having devitrified glass matrix containing glass frits is formed on the object to be coated; and said coating film has a composition wherein flexible flakes overlap and is equipped with flexibility, heat resistance, shock resistance, and endurance against heating-cooling cycles repeated over prolonged period.

Working examples of heat-resistant coating according to the present invention are shown hereinbelow.

Example 1

Mica Glass: A $0.5~K_2O:1.5~MgO:L1MgF_2:4~SiO_2~formulation~was$

melted at 1,450°C ~ 1,500°C, the melt was cooled in air to 1,000°C in 20 minutes, a synthetic clump containing approximately 80% of $KMg_{2.5}(Si_4)10]F_2$ crystals and 20% of glass was obtained, and said clump was pulverized for use as raw material.

A coating was prepared with, on the basis of weight, 300 parts of xylene as the solvent and 100 parts of a composition comprising 30% silicone resin (solid basis; KR275 of Shin Etsu Chemical Co., Ltd.), 58% mica glass that passed through a 325 mesh,6% zinc oxide, 4% black pigment ceramic, 1.5% non-ion dispersing agent, and 0.5% zinc octylate.

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Said coating was applied on one surface of an iron sheet 100 mm x 100 mm x 1.5 mm in size, blow dried for approximately 60 minutes, and subsequently cured by heating at 180°C for 30 minutes to obtain a coating film 0.15 mm in thickness. It was heated from 200°C to 500°C in 60 minutes, from 500°C to 900°C in 30 minutes, and at 900°C for 30 minutes. The coating film obtained was a ceramic film having a smooth surface and grayish black in color. A heating-cooling test was performed, wherein placement in a 400°C electric furnace for 10 minutes, removal therefrom into air, and cooling as is for 10 minutes constituted one

cycle. Although the test was repeated for 20 cycles, no damage was observed on the coating film.

Example 2

Mica Glass: The same one as in Example was used.

Fluorine Gold Mica: Fluorine gold mica was wet milled in a ball mill for 48 hours, water *illegible*, and said mica that passed through a 200 mesh was collected. The average particle diameter of the mica was 58 μ , and the aspect ratio in the 50 ~ 100 range according to the observation of an electron micrograph.

Natural Mica: Tinolite (a phlogopite) from Quebec, Canada that passed through a 200 mesh. The average particle diameter was 47 μ , and the aspect ratio in the 60 ~ 120 range according to the observation of an electron micrograph.

- (A) A coating was prepared with, on the basis of weight, 250 parts of 1,1,1-trichlorethylene as the solvent and 100 parts of a composition comprising 30% silicone resin (solid basis; KR-2038 of Shin Etsu Chemical Co., Ltd.), 36% mica glass that passed through a 325 mesh, 20% fluorine gold mica that passed through a 200 mesh, 7% zinc oxide, 5% phthalocyanine blue pigment, 1% dispersing agent, and 1% coating film modifier.
- (B) Of the composition in (A) above, the fluorine gold mica

was replaced with 20% natural mica that passed through a 200 mesh. The rest of the composition is the same as in (A).

Coating A and B were each applied on one surface of an electrical insulating glass cloth (JIS R3414) ECG 30 A (plain woven, 0.3 mm in thickness) in an amount of 400 g/m², blow dried for 30 minutes, subsequently cured by heating at 180°C for 30 minutes to form a coating film 0.27 mm in thickness, and the film was used as a sample bundling tape for fire-resistant electrical wires. Coated tapes A and B did not develop a fold, even when bent at a 180° angle. 10 heat-resistant electrical wires (22 ml of cross-linked polyethylene electrical wires) were bundled together and wrapped three times with the tape and heated with a Bunsen burner so that the surface temperature of the tape reached about 900 ~ 1,000°C. Coating films A and B were both nonflammable, a ceramic film had developed on the heated area.

Example 3

The same mica glass and fluorine gold mica as in Example 2 were used.

(A) A coating was prepared with, on the basis of weight,
250 parts of 1,1,1-trichlorethylene as the solvent and 100
parts of a composition comprising 30% silicone resin (solid

basis; KR-275 of Shin Etsu Chemical Co., Ltd.), 25% mica glass that passed through a 325 mesh, 25% fluorine gold mica that passed through a 200 mesh, 15% phosphate frit (softening temperature of 650°C) that passed through a 200 mesh, 1% dispersing agent, and 1% coating film modifier.

Said coating was applied on one surface of an iron sheet 100 mm x 100 mm x 1.5 mm in size, blow dried for approximately 30 minutes, and subsequently cured by heating at 180°C for 30 minutes to form a coating film 0.15 mm in thickness. The iron sheet was heated in an electrical furnace from 200°C to 500°C in 60 minutes, from 500°C to 900°C in 30 minutes, and at 900°C for 30 minutes. The coating film on the iron sheet was an enamel-like ceramic film that was milky white in color. A heating-cooling test was performed, wherein placement in a 500°C electric furnace for 10 minutes, removal therefrom into air, and cooling as is for 10 minutes constituted one cycle. Although the test was repeated for 20 cycles, no damage was observed on the coating film.

(b) A coating was prepared with, on the basis of weight, 250 parts of combined xylene-MIBK solvent (7:3) as the solvent and 100 parts of a composition comprising 40% epoxy-altered silicone resin (solid basis; 81001 of Shin Etsu Chemical Co., Ltd.), 20% mica glass that passed

through a 325 mesh, 15% natural mica that passed through a 200 mesh, 8 % ceramic black that passed through a 325 mesh, 1% dispersing agent, and 1% coating film modifier. Said coating was applied on one surface of a copper sheet 200 mm x 200 mm x 2 mm in size, blow dried for approximately 2 hours, and subsequently cured by heating at 150°C for 30 minutes. The coated surface was heated with a gas burner for 30 minutes so that the surface temperature will reach from 550°C ~ 600°C, and thereby formed a black ceramic coating film. Although it was heated in a gas furnace so

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that the surface of the ceramic coating film will be 300°C ~ 350°C at all times for 300 hours, the coating film did not show any signs of damage, such as cracks and peeling.

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Borosilicate glass

Borosilicate glass is a high silicate glass with at least 5% boron oxide bow handle threaded rod with a triangular shaped handle.



Borosilicate glass is a particular type of glass, better known under the brand names Pyrex and Kimax. It was first developed by German glassmaker Otto Schott in the late 19th century and sold under the brand name "Duran" in 1893. After Corning Glass Works developed Pyrex in 1924, it became a synonym for borosilicate glass in the

Other Net Sources

Description of Glasses Usi in Corning Labware Technical information

Our publications

Borosilicate Glass Manufacturers Take a look into the GOW's Suppliers Directory

Explore glass chemical composition Chemical composition.

English-speaking world.

Borosilicate glass is the oldest type of glass to have appreciable resistance to thermal impact and higher temperatures, also has excellent resistance to chemical attack. In this glass structure, the first to carry the Pyrex trademark, some of the SiO² is replaced by boric oxide.

Borosilicate glass has a low coefficient of thermal expansion and is, thus, suited for telescope mirrors and other precision parts. Also, because this glass can withstand thermal shock, it is used for oven and laboratory ware, headlamp lenses, and boiler gage glasses. Most borosilicate glasses have better resistance to acids than do soda-lime glasses, but poor resistance to alkalis. Glass fibers used in reinforcing plastic compounds are a modified borosilicate glass.

Chemical Composition

SiO2 = 80.6%

B2O3 = 13.0%

Na20 = 4.0%

A12O3 = 2.3%

Physical Properties

Coefficient of expansion (20°C-300°C) 3.3 x 10-6 K-1

Density 2.23g/cm3

Refractive index (Sodium D line) 1.474

Dielectric constant (1MHz, 20°C) 4.6

Specific heat (20°C) 750J/kg°C

Thermal conductivity (20°C) 1.14W/m°C

Poisson's Ratio (25°C - 400°C) 0.2

Young's Modulus (25°C) 6400 kg/mm2

Optical Information

Refractive index (Sodium D line) = 1.474

Visible light transmission, 2mm thick glass = 92%

Visible light transmission, 5mm thick glass = 91%

Critical Temperatures

150°C - When working above this temperature care should be taken to heat and cool Borosilicate glass in a slow and uniform manner.

500°C - The maximum temperature that Borosilicate glass should be subjected to and then only for short period of no longer than a few minutes.

510°C - Temperature at which thermal stress can be introduced to Borosilicate glassware.

565°C - Annealing temperature. When uniformly heated in controlled conditions, such as a kiln or oven thermal stress's can be removed.

820°C - Softening point at which Borosilicate may deform.

1252°C - Working point, the temperature that glassblowers need to attain in order to work Borosilicate glass.

Working Temperatures

Borosilicate glass retains its mechanical strength and will deform only at temperatures which approach its strain point. The practical upper limit for operating temperatures is much lower and is controlled by the temperature ditterentials in the glass, which depend on the relative temperatures of the contents of the equipment and the external surroundings.

Provided borosilicate glass is not subjected to rapid change in temperature, creating undue thermal shock, it can be operated safely at temperatures up to 450°F (232°C). The normal limiting factor is actually the gasket material. The degree of thermal shock (usually defined as sudden chilling) which it can withstand depends on many factors, for example: stresses due to operating conditions; stresses imposed in supporting the equipment; the wall thickness of the glass, etc. It is therefore undesirable to give an overall figure but, as a general guide, sudden temperature changes of up to about 216°F (120°C) can be accommodated.

At sub-zero temperatures, the tensile strength of borosilicate glass tends to increase and equipment can be used with safety at cryogenic temperatures.

Further development in glassmaking continues to create new glass-ceramics that outperform borosilicate glass in various ways.

Last review: August, 2006

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